

Electronic Supplementary Information:

**Synergism of Multiple Functional Chromophores Significantly Enhancing the
Birefringence in Layered Non-Centrosymmetric Chalcogenide**

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Table S1 Materials with experimentally measured birefringence larger than 0.100 and visible transmittance, which are containing one and two functional chromophores.

Compounds	Space groups	Δn	Band gap (eV)
One functional chromophore			
NaNO_2 ¹	<i>Im2m</i>	0.30	3.32
$\text{Y}_2\text{C}_{12}\text{N}_{12}\text{O}_{24}\text{H}_{30}$ ²	<i>P-1</i>	0.274 (@ 3482 nm)	5.20
$\text{Gd}_2\text{C}_{12}\text{N}_{12}\text{O}_{24}\text{H}_{30}$ ²	<i>P-1</i>	0.264 (@ 3874 nm)	5.29
TiO_2 ³	<i>P4_2/mnm</i>	0.256 (@ 1530 nm)	3.10
$\text{LaC}_6\text{N}_6\text{O}_9\text{H}_9$ ²	<i>P2_1/c</i>	0.233 (@ 1912 nm)	5.00
TbVO_4 ⁴	<i>I4_1/amd</i>	0.22 (@ 1064 nm)	2.79
$\text{RbNa}(\text{HC}_3\text{N}_3\text{O}_3) \cdot 2\text{H}_2\text{O}$ ⁵	<i>Pna2_1</i>	0.194 (@ 1922 nm)	5.10
$\text{LiNa}_5\text{Mo}_9\text{O}_{30}$ ⁶	<i>Fdd2</i>	0.1935 (@ 1062.6 nm)	3.47
$\text{KLi}(\text{HC}_3\text{N}_3\text{O}_3) \cdot 2\text{H}_2\text{O}$ ⁷	<i>Pna2_1</i>	0.186 (@ 514 nm)	5.23
$\text{C}_6\text{H}_7\text{O}_6\text{Li} \cdot \text{H}_2\text{O}$ ⁸	<i>P2_12_12_1</i>	0.174□ (@ 1064 nm)	4.20
CaCO_3 ⁹	<i>R-3c</i>	0.172 (@ 1064 nm)	5.39
$\text{Sn}_2\text{B}_5\text{O}_9\text{Cl}$ ¹⁰	<i>Pnn2</i>	0.168 (@ 546 nm)	3.53
$\alpha\text{-LiIO}_3$ ¹¹	<i>P63</i>	0.1401 (@ 1064 nm)	4~4.5
KNbO_3 ¹²	<i>Amm2</i>	0.1323 (@ 1064 nm)	3.1□0
KIO_3 ^{13, 11b}	<i>R3m</i>	0.1276 (@ 1064 nm)	3~4.5
$\text{Ca}(\text{BO}_2)_2$ ¹⁴	<i>Pbcn</i>	0.124 (@ 1064 nm)	7.34
$\text{Ba}_2\text{Ca}(\text{B}_3\text{O}_6)_2$ ¹⁵	<i>R-3</i>	0.1241 (@ 589.3 nm)	6.97
$\text{GdAl}_3(\text{BO}_3)_4$ ¹⁶	<i>R32</i>	0.12	7.09
$\text{RbBaYB}_6\text{O}_{12}$ ¹⁷	<i>R-3</i>	0.120 (@ 589 nm)	6.36
$\text{CsBaYB}_6\text{O}_{12}$ ¹⁷	<i>R-3</i>	0.120 (@ 589 nm)	6.39
$\alpha\text{-BaB}_2\text{O}_4$ ^{9a}	<i>R-3c</i>	0.116 (@ 1064 nm)	6.56
$\text{Na}_3\text{Ba}_2(\text{B}_3\text{O}_6)_2\text{F}$ ¹⁸	<i>P6_3/m</i>	0.1149 (@ 532 nm)	7.09
$\beta\text{-BaB}_2\text{O}_4$ ^{19, 11b}	<i>R3c</i>	0.1125 (@ 1064 nm)	7.00
$\text{Te}_2\text{P}_2\text{O}_9$ ²⁰	<i>Cc</i>	0.10615 (@ 1013.98 nm)	4.30
KTiOAsO_4 ^{19, 11b}	<i>Pna2_1</i>	0.106 (@ 1064 nm)	3.60
KSrCO_3F ²¹	<i>P-6m2</i>	0.1049 (@ 1064 nm)	6.36
$\text{Ba}_2\text{Mg}(\text{BO}_3)_2$ ²²	<i>R-3m</i>	0.10422 (@ 546 nm)	6.63
Two functional chromophores			
$\text{Sb}[\text{NH}_2\text{CSNH}_2]_2\text{Br}_3$ ²³	<i>Cmc2_1</i>	0.428 (@ 589.3 nm)	4.96□
SbB_3O_6 ²⁴	<i>C2</i>	0.290 (@ 546 nm)	3.95
$\alpha\text{-BaTeW}_2\text{O}_9$ ²⁵	<i>Pnma</i>	0.247 (@ 404.7 nm)	3.42
$\beta\text{-BaTeMo}_2\text{O}_9$ ²⁶	<i>P2_1</i>	0.226 (@ 1068 nm)	3.10
CdTeMoO_6 ²⁷	<i>P-42_1m</i>	0.2222 (@ 1311 nm)	3.59
$\alpha\text{-BaTeMo}_2\text{O}_9$ ²⁸	<i>Pca2_1</i>	0.20689 (@ 1064 nm)	3.12
$\alpha\text{-BiB}_3\text{O}_6$ ²⁹	<i>C2</i>	0.1747 (@ 1064 nm)	4.32
$\text{Cs}_2\text{TeW}_3\text{O}_{12}$ ³⁰	<i>P6_3</i>	0.1648 (@ 1013.98 nm)	3.02
$\text{Cs}_2\text{TeMo}_3\text{O}_{12}$ ³¹	<i>P6_3</i>	0.1476 (@ 1014 nm)	2.88
$\text{Na}_2\text{TeW}_2\text{O}_9$ ³²	<i>Cc</i>	0.1471 (@ 1062.6 nm)	3.47
YVO_4 ^{9a}	<i>I4_1/amd</i>	0.208 (@ 1064 nm)	3.1□0

Compounds	Space groups	Δn	Band gap (eV)
$\text{NH}_4\text{B}_4\text{O}_6\text{F}$ ³³	<i>Pna2</i> ₁	0.1171 (@ 1064 nm)	7.95
$\text{CsB}_4\text{O}_6\text{F}$ ³⁴	<i>Pna2</i> ₁	0.114 (@ 1064 nm)	8.00
$[\text{Al}(\text{H}_2\text{O})_6](\text{IO}_3)_2(\text{NO}_3)$ ³⁵	<i>P-3m1</i>	0.253 (@ 546 nm)	4.00

Table S2 Calculated band gaps and experimental volumes of $\text{Hg}_3\text{AsQ}_4\text{X}$ (Q = S, Se; X = Cl, Br, I).

Compounds	Band gap (eV)			Volume (\AA^3)
	LDA	GGA	HSE06	
$\text{Hg}_3\text{AsS}_4\text{Cl}$	1.34	1.83	2.34	430.539
$\text{Hg}_3\text{AsS}_4\text{Br}$	1.42	1.84	2.44	447.682
$\text{Hg}_3\text{AsSe}_4\text{Br}$	1.24	1.77	2.02	487.034
$\text{Hg}_3\text{AsSe}_4\text{I}$	1.39	1.68	1.93	510.496

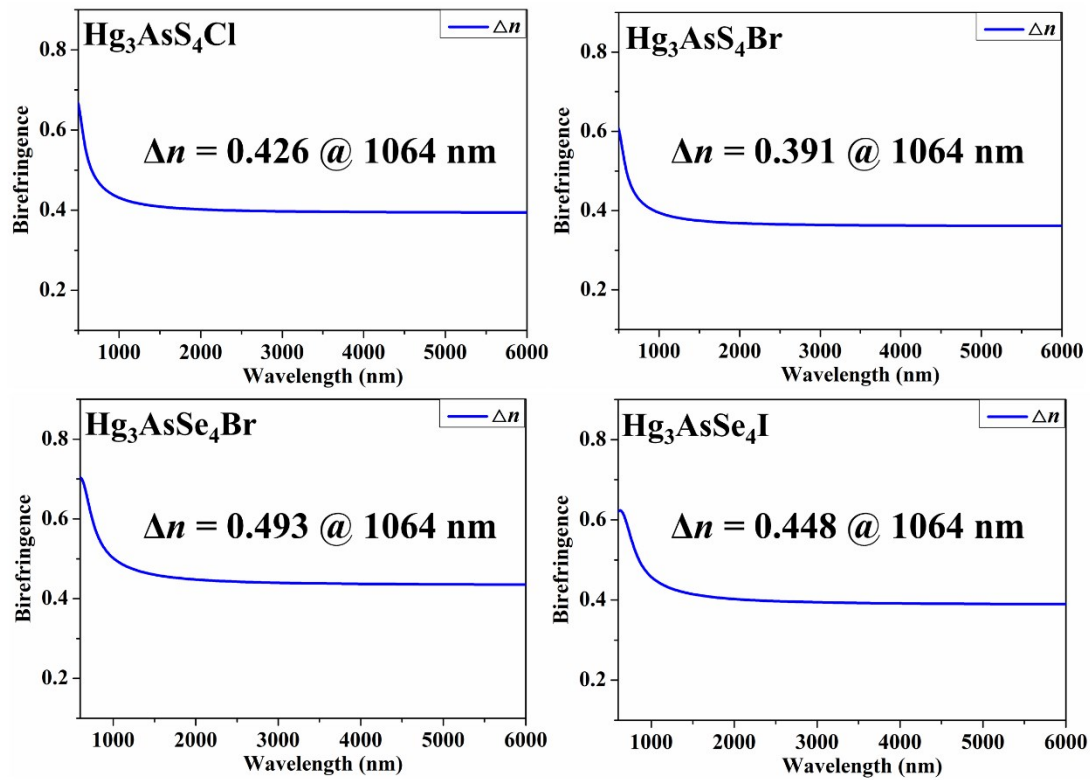


Figure S1 Calculated birefringence for $\text{Hg}_3\text{AsQ}_4\text{X}$ (Q = S, Se; X = Cl, Br, I).

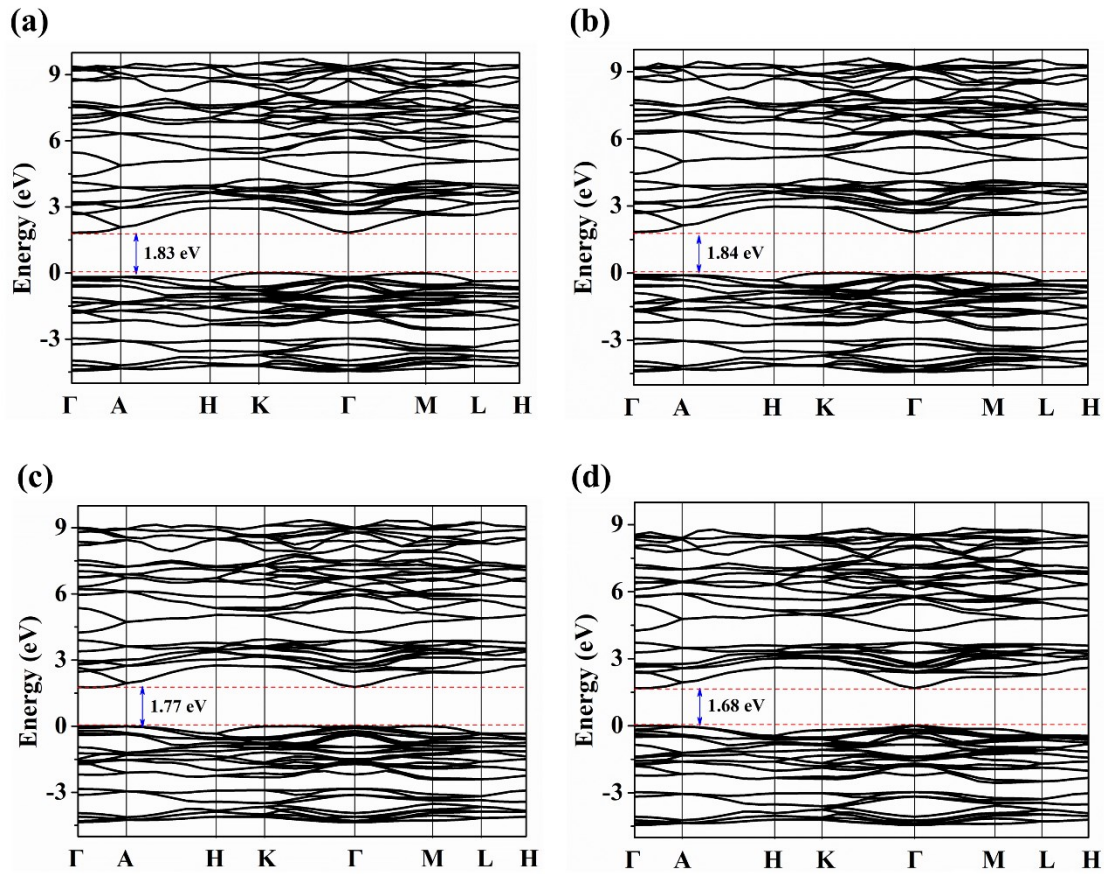


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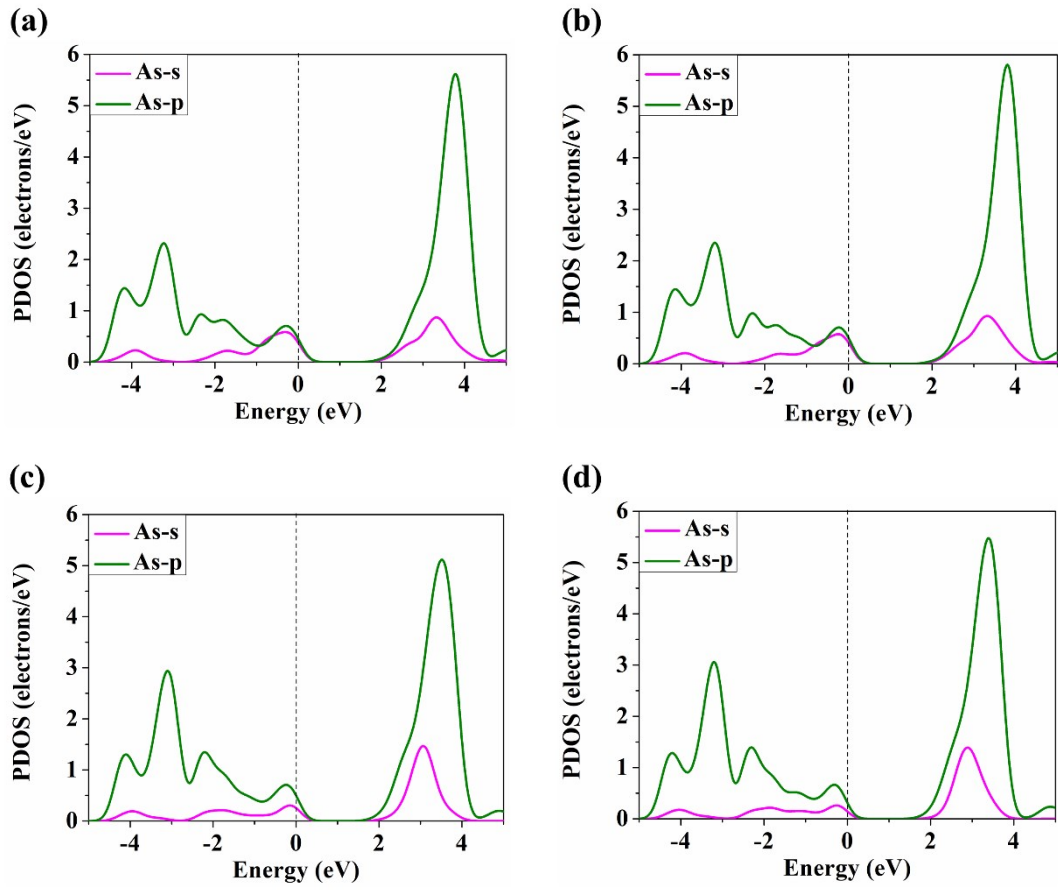


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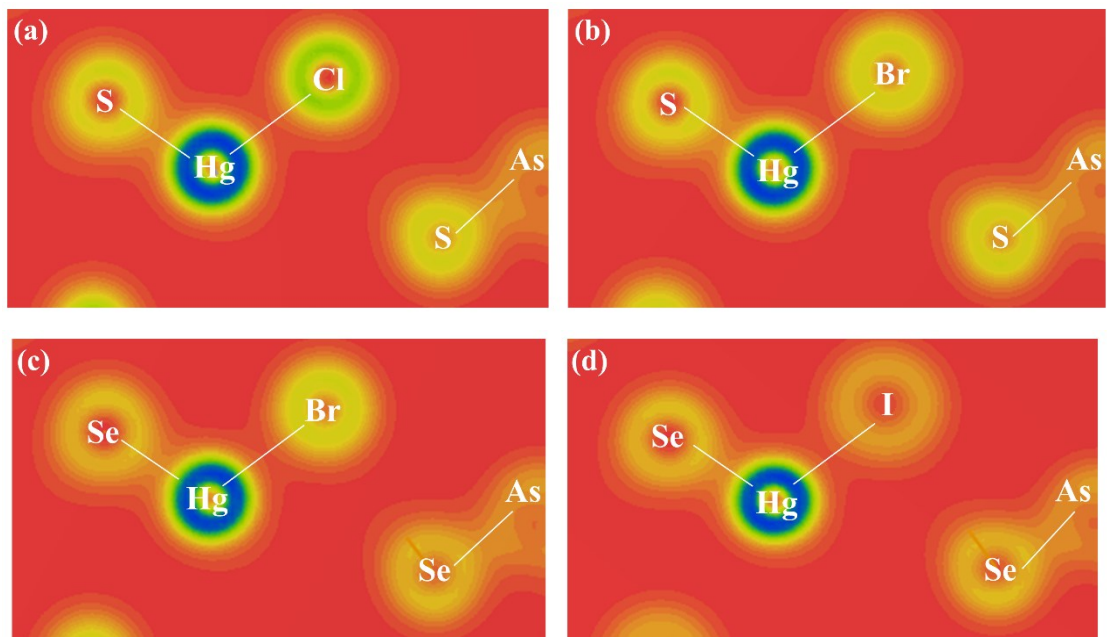


Figure S4 Calculated charge density of Hg₃AsS₄Cl (a), Hg₃AsS₄Br (b), Hg₃AsSe₄Br (c), and Hg₃AsSe₄I (d).

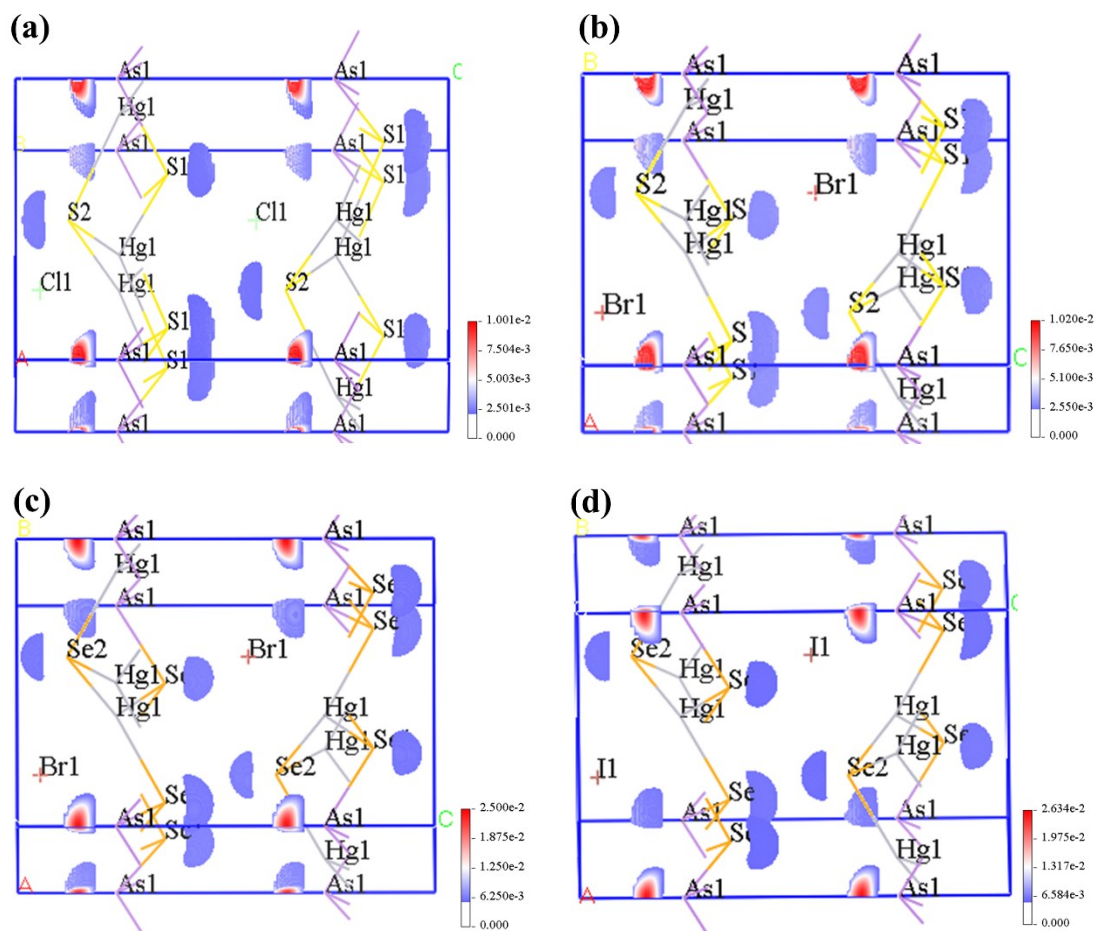


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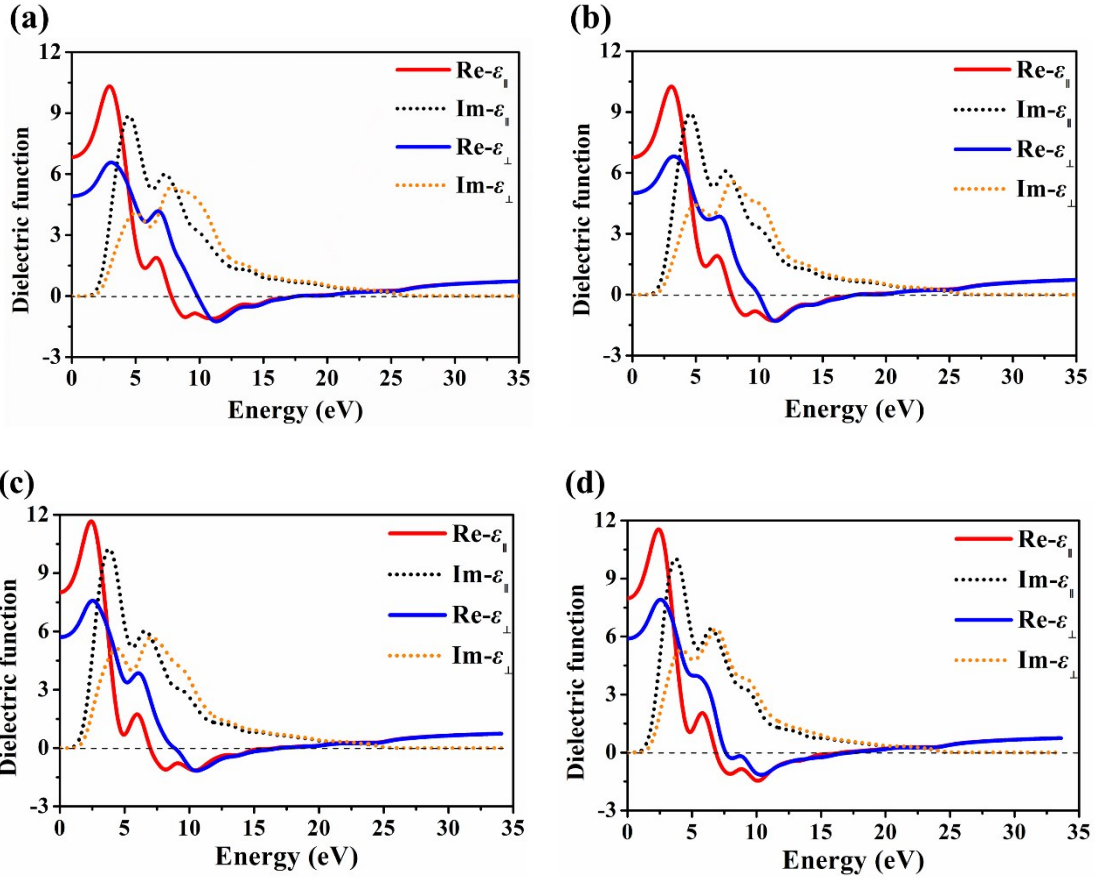


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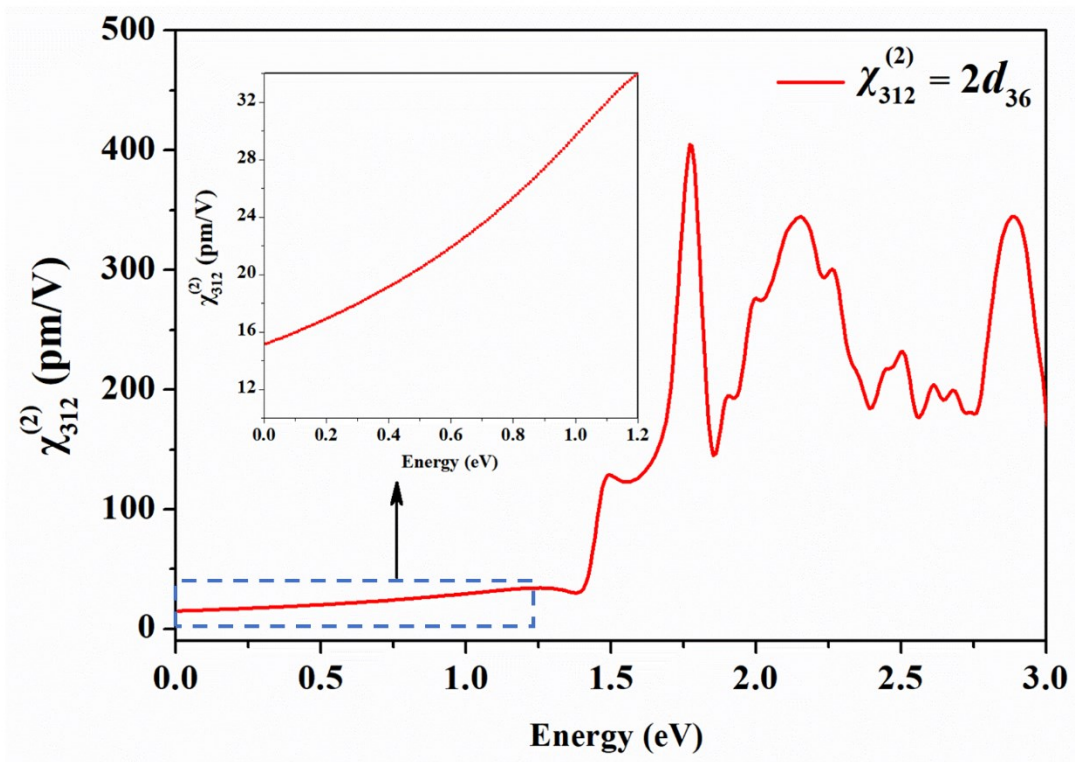


Figure S7 Calculated frequency-dependent SHG coefficients of AgGaS_2 ($\chi_{312}^{(2)} = 2d_{36}$) from sum-over-states (SOS) approximation by the *ab-initio* method.

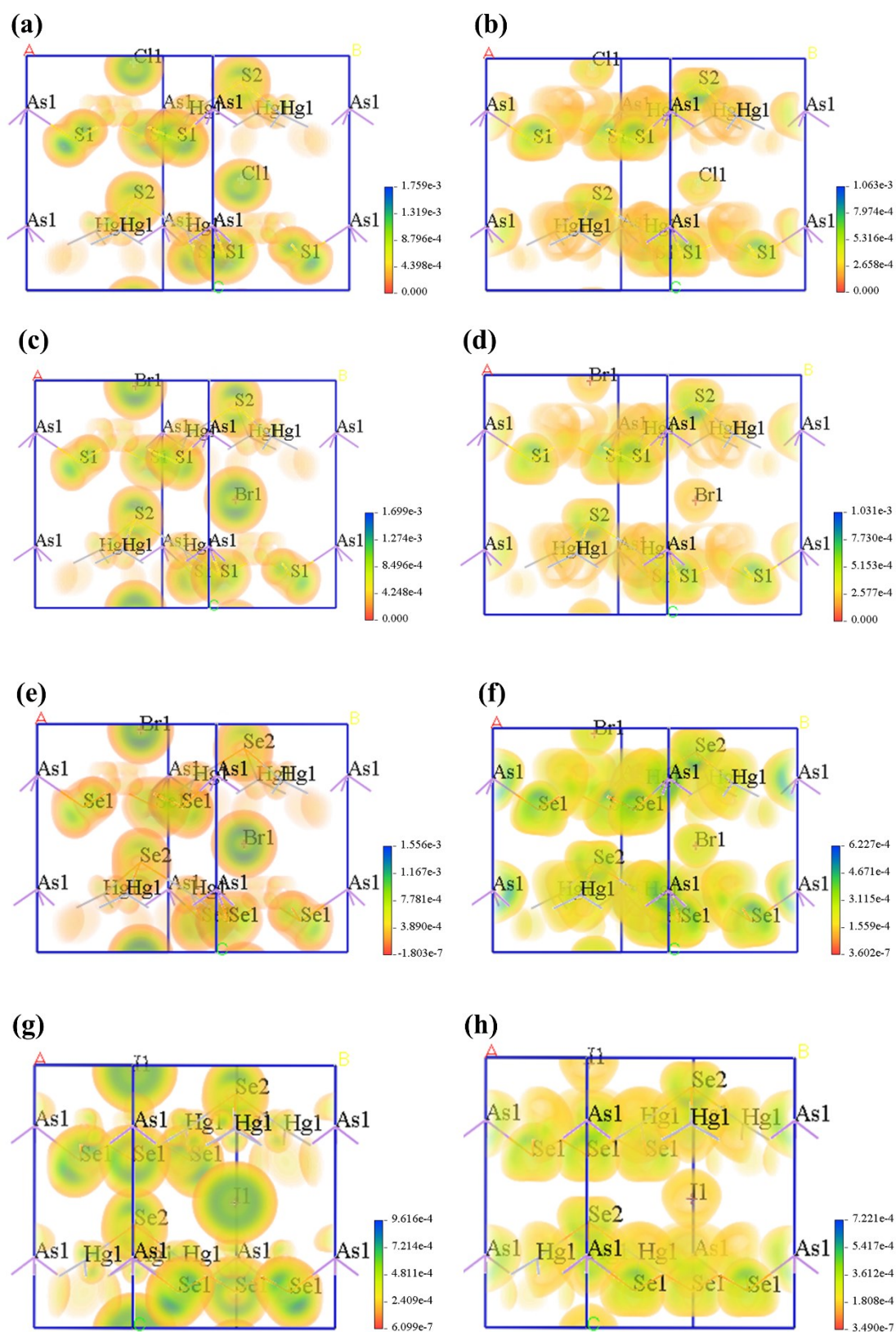


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